AMENDMENTS TO THE CLAIMS:

This listing of claims will replace all prior versions, and listings, of claims in the application:

LISTING OF CLAIMS

1-70. (canceled)

71. (currently amended) A semiconductor device having a semiconductor multi-layer structure which includes at least an active layer having at least a quantum well, and said active layer further including at least [[a]] one luminescent layer of $In_xAl_yGa_1-x-yN$ (0<x<1, 0<y<0.2), and at least a part of said at least one luminescent layer acting as at least a quantum well, wherein said semiconductor device satisfies at least one of:

a first condition that a threshold mode gain of each of said at least quantum well is more than 12 cm $^{-1}$, and

a second condition that said semiconductor device has an internal loss " $\alpha_{\underline{i}}$ " (cm⁻¹) which satisfies $\alpha_{\underline{i}} > 12 \times n - \alpha_{\underline{m}}$ (cm⁻¹), where " $\alpha_{\underline{m}}$ " is a mirror loss, and "n" is a number of said at least quantum well; and

a third condition that said semiconductor device has a slope efficiency "S" (W/A) which satisfies: S < $3\times\{\alpha_{\underline{m}}\}$ $/(12\times n)$ $\times [\{(1-R_1)\sqrt{(R_2)}\}/\{(1-\sqrt{(R_1R_2)})\times(\sqrt{(R_1)}+\sqrt{(R_2)})\}]$, where

"R1" is a first reflectance of a first cavity facet, from which a light is emitted, "R2" is a second reflectance of a second cavity facet opposite to said first cavity facet, " $\alpha_{\underline{m}}$ " is a mirror loss, and "n" is a number of said at least quantum well, and wherein said semiconductor device further satisfies at least one of:

- a fourth condition that a differential gain "dg/dn" of said at least active layer satisfies $dg/dn \ge 1.0 \times 10^{-20}$ (m²); and
- a fifth condition that standard deviations of microscopic and macroscopic fluctuations in a band gap energy of said at least luminescent layer are not more than of 40 meV.
 - 72. (canceled)
 - 73. (canceled)
 - 74. (canceled)
- 75. (currently amended) The semiconductor device as claimed in claim [[74]] 71, wherein said semiconductor device has a cavity length "L" of not less than 1000 micrometers, and said first reflectance "R1" is not more than 20%, said second reflectance "R2" is not less than 80% and less than 100%, and said slope efficiency "S" satisfies S < 2.1/n (W/A).
- 76. (currently amended) The semiconductor device as claimed in claim 71, wherein said semiconductor device

<u>luminescent layer</u> has a photo-luminescence peak wavelength distribution of not more than 40 meV.

- 77. (original) The semiconductor device as claimed in claim 71, wherein said semiconductor multi-layer structure comprises a gallium-nitride-based multi-layer structure.
- 78. (original) The semiconductor device as claimed in claim 77, wherein said gallium-nitride-based multi-layer structure extends over a gallium-nitride-based substrate.
- 79. (original) The semiconductor device as claimed in claim 77, wherein said gallium-nitride-based multi-layer structure extends over a sapphire substrate.
- 80. (original) The semiconductor device as claimed in claim 77, wherein said gallium-nitride-based multi-layer structure extends over a substrate having a surface dislocation density of less than 1×10^8 /cm².

81-120. (canceled)

- 121. (new) The semiconductor device as claimed in claim 71, wherein a standard deviation " $\Delta_{\rm X}$ " in the "microscopic fluctuation" of the indium composition is not more than 0.067.
- 122. (new) The semiconductor device as claimed in claim 121,

wherein said semiconductor device has a slope efficiency "S" (W/A) which satisfies:

 $S < 3 \times \{\alpha_m \ / (12 \times n)\} \times [\{(1-R_1)\sqrt{(R_2)}\}/\{(1-\sqrt{(R_1R_2)}) \times (\sqrt{(R_1)+\sqrt{(R_2)}})\}], \text{ where "R_1" is a first reflectance of a first cavity facet, from which a light is emitted, "R_2" is a second reflectance of a second cavity facet opposite to said first cavity facet, "α_m" is a mirror loss, and "n" is a number of said at least one quantum well.$

123. (new) The semiconductor device as claimed in claim 122, wherein said semiconductor device has a cavity length "L" of not less than 1000 micrometers, and said first reflectance "R1" is not more than 20%, said second reflectance "R2" is not less than 80% and less than 100%, and said slope efficiency "S" satisfies S < 2.1/n (W/A).

124. (new) The semiconductor device as claimed in claim 121, wherein said semiconductor device has an internal loss " α_i " (cm⁻¹) which satisfies $\alpha_i > 12 \times n - \alpha_m$ (cm⁻¹), where " α_m " is a mirror loss, and "n" is a number of said at least one quantum well.

125. (new) The semiconductor device as claimed in claim 121, wherein said semiconductor device has a photo-luminescence peak wavelength distribution of not more than 40 meV in said active layer.

- 126. (new) The semiconductor device as claimed in claim 121, wherein said substrate is a gallium-nitride-based substrate.
- 127. (new) The semiconductor device as claimed in claim 121, wherein said substrate is a sapphire substrate.
- 128. (new) The semiconductor device as claimed in claim 121, wherein said substrate has a surface dislocation density of less than 1×10^8 /cm².

AMENDMENTS TO THE DRAWINGS:

The attached sheets of drawings include changes to Figures 1-18. These sheets, which include Figures 1-18 replace the original sheets including Figures 1-18. Figures 1-18 are the same as the original drawings and are edited to improve the quality of the drawing lines and numbers. Figures 7 and 8 have also been amended, wherein the term " $E_{\rm G}$ fluctuation" has been changed to read "Standard deviation of $E_{\rm G}$ fluctuation".

Attachment: Replacement Sheets